

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	881	(etch\$3 same metal near plate) same mask\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/08/05 12:23
L2	51	L1 same mold\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/08/05 12:24
L3	369	polymer\$3 same (electrophoretic near deposit\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/08/05 12:26
L4	41	L3 same (metal same etch\$3 or pattern\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/08/05 12:29
L5	25	4 and @pd<"20030223"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/08/05 12:30
L6	37	light-david.in.	US-PGPUB; USPAT	OR	OFF	2007/08/05 13:17
L7	84460	((REUSABLE NEAR MOLD\$3) AND MASK\$3 AND RECESS OR GROOVE AND OPEN\$3).CLM.	US-PGPUB; USPAT	OR	OFF	2007/08/05 13:18
L8	726	7 and ((semiconductor or microelectronic) and packag\$3)	US-PGPUB; USPAT	OR	OFF	2007/08/05 13:20
L9	333	8 and @pd<"20030223"	US-PGPUB; USPAT	OR	OFF	2007/08/05 13:21
L10	0	9 and (attach\$3 near mask\$3)	US-PGPUB; USPAT	OR	OFF	2007/08/05 13:21